

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of YAMAMURA et al.

Confirmation No.: 1705

Serial No.: 09/924,116

Group Art Unit 1711

Filed: August 8, 2001

Examiner: S. Berman

Title: PHOTCURABLE LIQUID RESIN COMPOSITION

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May 20, 2003

AMENDMENT

Mail Stop Non-Fee Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated February 21, 2003, please consider the following amendments and remarks regarding the above-identified application.

IN THE CLAIMS

Please cancel claims 49-50 without prejudice or disclaimer.

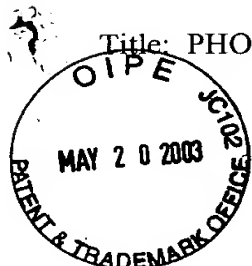
Please amend claims 33 and 51 as follows:

33. (Twice Amended)

A photocurable resin composition comprising:

- (A) an epoxy compound having two or more alicyclic epoxy groups;
- (B) a cationic photopolymerization initiator;
- (C) a polyfunctional monomer having two or more ethylenically unsaturated groups in one molecule;
- (D) a radical photopolymerization initiator;
- (E) a polyol having three or more hydroxyl groups in one molecule; and
- (F) core shell particles having an average particle diameter of 10-700 nm, wherein said core shell particles include

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